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| APPLICANTS Kazuo Nishimoto, Tokyo, JAPAN; Tatsuaki Sakano, Tokyo, JAPAN; Akihiro Takemura, Tokyo, JAPAN; Masayuki Hattori, Tokyo, JAPAN; Nobuo Kawahashi, Tokyo, JAPAN; Naoto Miyashita, Yokohama-shi, JAPAN; Atsushi Shigeta, Fujisawa-shi, JAPAN; Yoshitaka Matsui, Yokohama-shi, JAPAN; Kazuhiko Ida, Yokohama-shi, JAPAN; | | | | | |
| ** CONTINUING DATA ***** NONE MM | | | | | |
| ** FOREIGN APPLICATIONS ***** JAPAN 2002-318643 10/31/2002 JAPAN 2003-056093 03/03/2003 YES MM | | | | | |
| IF REQUIRED, FOREIGN FILING LICENSE GRANTED ** 01/28/2004 | | | | | |
| Foreign Priority claimed <input checked="" type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 (a-d) conditions met <input checked="" type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> Met after Allowance Verified and Acknowledged Examiner's Signature <i>MM</i> Initials <i>ll</i> | | STATE OR COUNTRY JAPAN | SHEETS DRAWING 0 | TOTAL CLAIMS 23 | INDEPENDENT CLAIMS 3 |
| ADDRESS 22850 OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C. 1940 DUKE STREET ALEXANDRIA, VA 22314 | | | | | |
| TITLE Aqueous dispersion for chemical mechanical polishing, chemical mechanical polishing process, production process of semiconductor device and material for preparing an aqueous dispersion for chemical mechanical polishing | | | | | |